W

	Application No.	Applicant(s)
	10/619,797	ERHARDT ET AL.
Notice of Allowability	Examiner	Art Unit
	Michael Trinh	2822
The MAILING DATE of this communication appear All claims being allowable, PROSECUTION ON THE MERITS IS (herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGOT THE Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this ap or other appropriate communication GHTS. This application is subject t	plication. If not included will be mailed in due course. THIS
1. This communication is responsive to Election 9/16/04 and	Telephone Interview 9/23/04.	
2. The allowed claim(s) is/are <u>1-13</u> .		
3. \boxtimes The drawings filed on <u>14 July 2003</u> are accepted by the Exa	aminer.	
 4. Acknowledgment is made of a claim for foreign priority unally all b) Some* c) None of the: 1. Certified copies of the priority documents have 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority documents have International Bureau (PCT Rule 17.2(a)). * Certified copies not received: 	been received. been received in Application No	
Applicant has THREE MONTHS FROM THE "MAILING DATE" of noted below. Failure to timely comply will result in ABANDONMI THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	of this communication to file a reply ENT of this application.	complying with the requirements
5. A SUBSTITUTE OATH OR DECLARATION must be submit INFORMAL PATENT APPLICATION (PTO-152) which give	tted. Note the attached EXAMINER s reason(s) why the oath or declara	S AMENDMENT or NOTICE OF ation is deficient.
 6. CORRECTED DRAWINGS (as "replacement sheets") must (a) including changes required by the Notice of Draftsperson 1) hereto or 2) to Paper No./Mail Date (b) including changes required by the attached Examiner's Paper No./Mail Date Identifying indicia such as the application number (see 37 CFR 1.8 each sheet. Replacement sheet(s) should be labeled as such in the paper No./Mail DFPOSIT OF and/or INFORMATION about the depose attached Examiner's comment regarding REQUIREMENT F 	on's Patent Drawing Review (PTO Amendment / Comment or in the C 84(c)) should be written on the drawing he header according to 37 CFR 1.121(sit of BIOLOGICAL MATERIAL I	Office action of ngs in the front (not the back) of d). must be submitted. Note the
 Attachment(s) 1. ☑ Notice of References Cited (PTO-892) 2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948) 3. ☑ Information Disclosure Statements (PTO-1449 or PTO/SB/08 Paper No./Mail Date 9/26/03 4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material 	6. ⊠ Interview Summary Paper No./Mail Da 8), 7. ⊠ Examiner's Amendi	tè <u>20040923</u> .

Application/Control Number: 10/619,797 Page 2

Art Unit: 2822

DETAILED ACTION

*** This office action is in response to filling of the Application on July 14, 2003.

Restriction & Election

1. During a telephone conversation with Mr. Andrew Romero on September 16, 2004 a provisional election was made with traverse to prosecute the invention of method claims 1-13.

** Claims 14-20 are withdrawn from further consideration by the examiner, 37 CFR 1.142(b), as being drawn to a non-elected invention.

Examiner's Amendment

- 2. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.
- 3. Authorization for this Examiner's Amendment was given in a telephone interview with Mr. Andrew Romero on September 23, 2004.

IN THE CLAIMS:

- * Cancel non-elected claims 14-20.
- * In claim 1, line 6, after "pattern in", change "in the hard" to --in the first hard--.
- * In claim 1, line 10, after "pattern in", change "the hard mask" to --the first hard mask--.
- * In claim 1, line 17, after "line in", change "the hard mask" to --the first hard mask--.
- * In claim 1, line 25, after "pattern in", change "the hard mask" to --the first hard mask--
- *** In claim 2, line 2, after "comprises", insert --a material of--.
- *** Claim 3, line 1, after "the layer includes", insert --a material of --.

Allowable Subject Matter

- 4. Claims 1-13 are allowed.
- 5. The following is a statement of reasons for the indication of allowable subject matter:

The references including Tani (5,290,723), Kimoshita (6,780,708), Singh (6,416,933), etc., of record, alone or in combination, do not anticipatively disclose each and every aspect of the claimed method of forming a layer comprising a line and space pattern over a substrate

Art Unit: 2822

including a first region and a second region, or fairly make a prima facie obvious case of the claimed method, in combination with other processing claimed limitations as recited in base claim, the inclusion of etching the layer to form the line and space pattern in the second region corresponding to the first master line and space pattern in the first hard mask layer in the second region, wherein a line in the second region includes a first critical dimension (B) achievable at the resolution limit, wherein a first master line and space pattern in the first hard mask layer includes at least one line and at least one space of a minimum dimension dictated by a resolution limit of lithography; depositing a second hard mask layer over the patterned first hard mask layer; etching the second hard mask layer to form spacers on sidewalls of at the least one line in the first hard mask layer in the first region, wherein the minimum dimension of the at least one space in the first hard mask layer in the first region is reduced to a second critical dimension (A) less than achievable at the resolution limit, to form spacers on sidewalls of the at least one line in the second region; and etching the layer to form the line and space pattern in the first region corresponding to the first master line and space pattern in the first hard mask layer in the first region, wherein a space in the first region includes the second critical dimension (A) less than achievable by the resolution limit.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Michael M. Trinh whose telephone number is (571) 272-1847. The examiner can normally be reached on M-F: 8:30 Am to 5:00 Pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Amir Zarabian can be reached on (571) 272-1852. The fax phone numbers for the organization where this application proceeding is (703) 872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

Oacs-3

Michael Trinh Primary Examiner